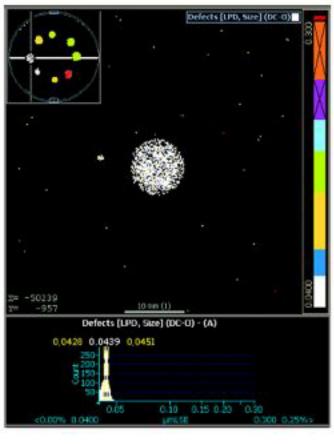
Model 2300 NPT-2 Automated Particle Deposition System

Nano Particle Technology to Produce PSL Wafer Standards & Particle Wafers for WET Process Benches & Wafer Inspection Systems, 20nm-3 µm





Dual Cassette FOUP for 300mm and 200mm Bridge Applications; Recipe Control; 10 Quick Change PSL Sizes; NIST SRM Calibration Mode; Exceeds SEMI M52 Size Accuracy; Full, Spot, Ring Depositions; CE Mark, SEMI S2, S8, S14



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